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| <p>Substitute for form 1449A/PTO</p> <p>Complete if Known</p> <p>OPT-E TAPED JUN 18 2003 INFORMATION DISCLOSURE STATEMENT BY APPLICANT</p> <p>(use as many sheets as necessary)</p> <p>Sheet 1 of 4</p> | | | |
| APPLICATION NUMBER | | 10/614,716 | |
| FILING DATE | | 07 July 2003 | |
| FIRST NAMED INVENTOR | | Sreenivasan et al | |
| GROUP ART UNIT | | 1722 | |
| EXAMINER NAME | | Emmanuel S. Luk | |
| ATTORNEY DOCKET NUMBER | | P90-32V30 | |

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| Examiner Signature |  | Date Considered | 9/26/06 |
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| Sheet | | 2 | of | 4 | |

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| OTHER PRIOR ART - NON PATENT LITERATURE DOCUMENTS | | | | | | |
| Examiner Initials* | Citeq No. | Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published. | | | | T ² |

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| EC | G7 | Translation of Japanese Patent 61-40845, 2/1/1986 | |
| EC | G8 | Translation of Japanese Patent 02-248480, 10/1/1990 | |
| EC | G9 | Translation of Japanese Patent 03-090345, 4/1/1991 | |
| EC | G10 | Translation of Japanese Patent 09-278490, 10/1/1997 | |
| EC | G11 | Abstract of Japanese Patent 03-090345, 4/1/1991 | |
| EC | G12 | Abstract of Japanese Patent 09-278490, 10/1/1997 | |
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| EC | G15 | FLETCHER ET AL., Microfabricated Silicon Solid Immersion Lens, Journal of Microelectromechanical Systems, Vol. 10, No. 3 9/1/2001 | |

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| EC | G16 | KHANDAKER ET AL., Fabrication of Microlens Arrays by Direct Electron Beam Exposure of Photoresist, Pure Appl. Opt. 6, pp. 637-641 1/1/1997 | |
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| EC | G23 | SANO ET AL., Submicron Spaced Lens Array Process Technology for a High Photosensitivity CCD Image Sensor, IEEE IEDM Dig.; pp. 283-286 1/1/1990 | |
| EC | G24 | TSUKAMOTO ET AL., High Sensitivity Pixel Technology for a 1/4 inch PAL 430k pixel IT-CCD, IEE Custom Integrated Circuits Conference 1/1/1996 | |

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| EC | G25 | YONEDA ET AL., Translation of Japanese Patent 02-248480, Transparent Substrate with Water-Repellent and Antistaining Properties, and Structure Equipped Therewith 10/4/1990 | |
| EC | G26 | YONEDA ET AL., Translation of Japanese Patent 02-248480, Transparent Substrate Material with Water-Repellent and Anti-Staining Properties and Structure Equipped with Same 10/4/1990 | |
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